X 8 -П ם П 🖳 Highlight all hit terms initially LEADERS EXPRESSION REPRESENTANT PROPERTY OF THE PROPERTY OF TH NC NC NC Perst. П Ď Σ Σ Σ Σ Σ Σ Σ Σ Σ e t ۹ e t et et et aj. al al al Woodruff, Daniel J. Woodruff, Daniel J. Woodruff, Daniel J. ٦. əţ t t et et 🔺 BRS form 🔼 IS&R form 🛣 image 🔢 Text 📴 HTMI Woodruff, Daniel Woodruff, Daniel Woodruff, Daniel Harris, Randy et Woodruff, Daniel ď Inventor McHugh, Paul R. α. Kyle M. Paul McHugh, Paul å McHugh, Hanson, Bentals List Browse Breass Breass Des US-PGPUB; USPAT al al Ŀ Current XRef 257/E21.174; Defeut gperator: ADJ 204/215; 204/242 204/224R 204/224R 204/198; 204/471; 204/279 OR wet 156/345.1 204/275.1 Current 204/224R Methods and apparatus for processing the 204/224R rotated or rotating).clm. 204/198 204/253 Methods and apparatus for processing the 204/242 204/198 204/242 204/212 205/89 205/80 Electroplating apparatus with segmented Method and apparatus for copper plating Apparatus with processing stations for Processing tools, components of processing tools, and method of making surface of a microelectronic workpiece surface of a microelectronic workpiece and/or enclosed reciprocating paddles, manually and automatically processing Reactor vessel having improved cup, Integrated tool with interchangeable processing components for processing Paddles and enclosures for enhancing Reactors having multiple electrodes Reactor vessel having improved cup, mass transfer during processing of processing tools with registration Integrated microfeature workpiece using electroless plating and anode and conductor assembly anode and conductor assembly rotates or or cathode).clm. 2/2005 08/680,067 inventor name search update (431900) (rotor or rotors or rotate or (18) 18 and 19 (273742) (electrode or anode "WOODRUFF DANIEL JS".in "BERNER ROBERT WS".in. Issue Date Pages "SCHMIDT WAYNE US".in. 42 21 13 33 37 24 43 43 (77) 16 not (11 or 15) Elle View Edit Iools Window Help A1 US 2005003480920050217 US 2005016132020050728 A1 US 20050000817 20050106 A1 US 20030047448 20030313 20050189213|20050901 2002010885120020815 A1 US 20020053510|20020509 us 2002005350920020509 2001002058320010913 A1 US 2005000624120050113 2004024509420041209 us 2003015992120030828 (10) 13 and 14 (38) 17 and 14 12 not 11 Hits (C) Details 📴 HTML MEAST - [Untitled1:1] (36) Document - Saved - Favorites - Tagged (0) (31)(83) **2** 11: (9) - Pending 1.9: ( ⊦@ Failed L.**'''** ( -O Drafts 4444412: 444412: 44412: 44412: 44413: O Dueue SO A1 US A1 US A1 A1 4 Ready

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